Supporting Information for:

## Sintering Copper nanoparticles with photonic additive for printed conductive patterns by intense pulsed light

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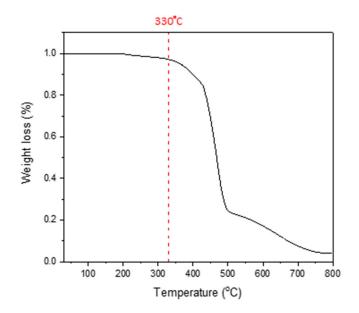
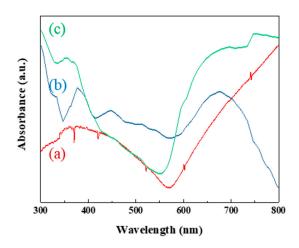


Figure S1 Thermogravimetric analysis of PVP.





**Figure S2**. UV-vis absorbance spectrum comparison of (a) CuNP, (b)CuONPs and (c) CuONP/CuNP mixture with a weight ratio of 1/80.



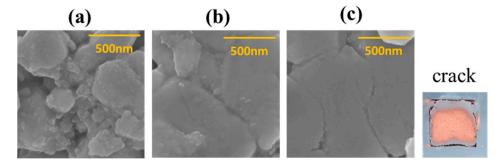


Figure S3. SEM images of sintered Cu/CuO film with sintering intensity at (a) 2.36 J/cm<sup>2</sup>, (b) 3.08 J/cm<sup>2</sup> and (c) 3.23 J/cm<sup>2</sup>.